	Application No.	Applicant(s)	
Notice of Allowability	08/427,866	SUGIYAMA ET AL.	
	Examiner	Art Unit	
	Hai C. Pham	2861	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT F of the Office or upon petition by the applicant. See 37 CFR 1.31	S (OR REMAINS) CLOSED i i) or other appropriate comm RIGHTS. This application is	n this application. If not included unication will be mailed in due course. <b>TH</b>	
1. This communication is responsive to <u>Amendment filed 04</u>	<u> 1/03/07</u> .		
2. The allowed claim(s) is/are 14-21 and 23-33.			
3. ☑ Acknowledgment is made of a claim for foreign priority to a) ☑ All b) ☐ Some* c) ☐ None of the:		or (f).	
<ol> <li>Certified copies of the priority documents have</li> <li>Certified copies of the priority documents have</li> </ol>		on No. 07/058 162	
Copies of the certified copies of the priority d	• •	· ·	
International Bureau (PCT Rule 17.2(a)).	ocuments have been receive	ed in this national stage application from the	6
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE noted below. Failure to timely comply will result in ABANDON THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		e a reply complying with the requirements	
4. A SUBSTITUTE OATH OR DECLARATION must be subinformal patent application (PTO-152) which gives			
5. CORRECTED DRAWINGS (as "replacement sheets") mu	ust be submitted.		
(a) ☐ including changes required by the Notice of Draftspe	rson's Patent Drawing Revie	w ( PTO-948) attached	
1) 🔲 hereto or 2) 🔲 to Paper No./Mail Date	<b>-</b>		
(b) ☐ including changes required by the attached Examine Paper No./Mail Date			
Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in			
6. DEPOSIT OF and/or INFORMATION about the dep attached Examiner's comment regarding REQUIREMENT	OSIT OF BIOLOGICAL MAT FOR THE DEPOSIT OF BI	ERIAL must be submitted. Note the OLOGICAL MATERIAL.	
Attachment(s)  1. Notice of References Cited (PTO-892)	5 Notice of I	nformal Patent Application	
Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview S	Summary (PTO-413),	
3. Information Disclosure Statements (PTO/SB/08),	Paper No 7. ☐ Examiner's	./Mail Date Amendment/Comment	
Paper No./Mail Date  4. Examiner's Comment Regarding Requirement for Deposit	8. 🛛 Examiners	Statement of Reasons for Allowance	
of Biological Material	9. 🗌 Other	<del></del>	

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## **REASONS FOR ALLOWANCE**

1. The following is an examiner's statement of reasons for allowance: claim 15 is allowed at least for the reason that the prior art of record does not teach or reasonably suggest the optical disk medium, comprising a substrate having a structure of an uneven-like shape on a flat surface; a first reflecting film formed on the substrate and having a surface contoured to the uneven-like shape of the substrate, for reflecting a light having a predetermined wavelength, a resin layer having an uneven-like shape on a flat surface directly formed on the first reflecting film, and a second reflecting film formed on the resin layer and having a surface contoured to the uneven-like shape of the resin layer, for reflecting a light having a predetermined wavelength, wherein the uneven-like shapes of the first and second reflecting films represent information, respectively, and wherein the first and second reflecting films lie in a range from a predetermined plane where a spherical aberration becomes substantially zero, to ±50 µm in a direction perpendicular to the substrate, as set forth in the claimed combination.

Claims 24, 26 and 28 are allowed at least for the reason that the prior art of record does not teach or reasonably suggest the optical disk medium comprising a substrate having a structure of an uneven-like shape thereon, a first film formed on the substrate and having a surface contoured to the uneven-like shape of the substrate; and an intermediate layer formed on the first film and having an uneven-like shape thereon; a second film formed on the intermediate layer and having a surface contoured to the uneven-like shape of the intermediate layer, wherein the uneven-like shapes of the first and second films represent information, respectively, and wherein the first and second

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films lie in a range from a predetermined plane where a spherical aberration becomes substantially zero, to  $\pm 50~\mu m$  in a direction perpendicular to the substrate, as set forth in the claimed combination.

The reasons for allowance of claims 14, 17-21, 23, 25, 27 and 29-33 have been stated in the office action issued on 05/24/06.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hai C. Pham whose telephone number is (571) 272-2260. The examiner can normally be reached on M-F 8:30AM - 5:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Luu can be reached on (571) 272-7663. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

HAI PHAM
PRIMARY EXAMINER

Har Elitham

May 29, 2007